

**STUDIES ON THE OPTICAL DISPERSION PARAMETERS
AND ELECTRONIC POLARIZABILITY OF CADMIUM
SULPHIDE THIN FILM.**

ABSTRACT

Thin film of Cadmium Sulphide (CdS) was deposited onto a precleaned transparent glass substrate by chemical bath deposition technique from a bath containing Cadmium acetate, ammonium acetate, thiourea and ammonium hydroxide. The deposition time was varied from 10 minutes to 50 minutes at an interval of 20 minutes keeping the bath at a constant temperature of 90°C using 78HW-1 constant magnetic stirrer. CdS thin film was characterized by UV-Visible spectrophotometer within the wavelength range of 280 nm – 920 nm using Single – Beam Helios Omega UV – VIS spectrophotometer. The optical parameters; extinction coefficient, refractive index and dielectric constant of CdS thin film were analyzed from the absorption spectra and were found to be affected by the deposition time. The optical band gap energy was obtained by Tauc's equation and were found to decrease from 3.78 eV – 3.70 eV as the deposition time increases. The dispersion parameters (dispersion energy E_d , oscillation energy E_o , moment of optical dispersion spectrum m_{-1} and m_{-3} , static dielectric constant ϵ_o and static refractive index η_o) were calculated using theoretical Wemple-DiDomenico model. The result show that only E_o and E_d behaved differently but other parameters increase as the deposition time increases. The oscillator strength S_o , oscillator wavelength λ_o , high frequency dielectric constant ϵ_∞ and high frequency refractive index η_∞ were calculated using single Sellmeier oscillator model. While S_o behaved differently other parameters increase as the deposition time increased. Also, Lattice dielectric constant ϵ_L , N/m³ and plasma resonance frequency ω_p were equally obtained. While ϵ_L decrease with increase in deposition time, N/m³ increase with deposition time. The electronic polarizability α_p of CdS thin film was estimated by Lorenz - Lorentz equation and Clausius Mossotti local field polarizability model. The value is an indication that the films showed good response on the application of photon energy. However, its response reduces as the deposition time increases.

Keywords: Dispersion parameter; Wemple-DiDomenico model; single Sellmeier oscillator model; Clausius-Mossotti local field polarizability; CdS thin film.

1. INTRODUCTION

The properties of Semiconductor materials are very important for determining their applicability in various fields. Moreover, in nanoscale some of the properties have been affected that made it differ from the bulk material especially the bandgap [1 – 4]. Since it is possible to adjust or tailor their electrical and optical properties especially when physical dimensions are reduced to a few nanometers which these properties depend upon, that

makes them useful for application in optoelectronics, nonlinear optics and photoelectrochemical solar cell devices [1,4,5,6]. "Dispersion parameters can be determined by parameterization of data. This is because these parameters depend on the dielectric functions of films and other corresponding function such as the bandgap, optical dispersion energies (E_o, E_d), dielectric constant (ϵ), ratio between the number of charge carriers and effective mass ($\frac{N}{M^*}$) wavelength of the single oscillator λ_o , and plasma frequency ω_p . These parameters, especially the optical constants provide information about the microscopic characteristics of the material" [7].

Chalcogenide semiconductors such as Cadmium Sulphide (CdS) have shown great usefulness and applicability in solar cells and optoelectronics such as linear and nonlinear optics, visible light diodes, and lasers [8,9]. "This is because CdS has wide bandgap, low absorption loss, compact crystallographic cell structure and electronic affinity" [10]. "Moreso, CdS, is most widely used as a window layer in CdTe thin film solar cells and is a buffer layer in Copper Indium and Gallium Selenide (CIGS) thin film solar cells" [11 – 15].

"Several deposition techniques have been studied and employed in the fabrication of CdS thin films such as spin coating[16], Electro deposition ED [17], physical vapour deposition PVD[18], spray pyrolysis [19, 20, 21], Successive ionic layer adsorption and reaction SILAR [22], chemical precipitation [23], Sol - gel deposition [24, 25], Thermal evaporation[26, 27], and Chemical bath deposition CBD" [2, 28, 29,30 31].

"Among all these techniques for synthesizing CdS, CBD has been adjudged to be the simplest, does not require sophisticated and complex machine, does not require high temperature and it is very cheap. Chemical bath deposition of CdS consists of a chemical bath of a salt which contains Cadmium cations and anions of either sulphates, nitrates, chlorides or acetates" [32]. "The properties of CdS thin films obtained by CBD depends on the preparative parameters, hence several studies have been carried out to optimize such parameters such as; bath temperature, pH of bath content, concentration of different precursors and deposition time" [33,34].

This paper reports the dispersion parameters of CdS thin films evaluated from the absorption spectra as a result of variation in deposition time in a chemical bath deposition technique. The accurate determination of these parameters is important not only to know the basic mechanisms but also the underlying phenomena and exploit and develop their interesting technological applications. The dispersion parameters considered are; dispersion energies (E_o, E_d), dielectric constant (ϵ), the average values of oscillator strength (S), wavelength of single oscillator λ , and plasma frequency ω_p . Also considered was the electronic polarizability using the Lorenz - Lorentz equation and Clausius Mossotti local field model.

2. EXPERIMENTAL DETAILS

CdS thin film was prepared according to our previous work [5] by using ultrasonically cleaned glass substrate of size (25.0x75.0x1.0) mm. The major precursors for CdS are aqueous solutions from Cadmium acetate for Cadmium source and Thiourea for Sulphide source while Ammonium acetate was used as the complexing agent. All the chemicals used were of analytical grades. The key precursors, Cadmium Acetate ($CdCH_3COO$, Sigma Aldrich, purity 98%) and Thiourea $Sc(NH_2)_2$ Merck, $\geq 98\%$, all were procured through Divine Chemicals Laboratory Ibeagwa Road, Nsukka Nigeria. The bath consists of 30 ml of $0.264gdm^{-3}$ of Cadmium acetate, 15ml of $0.158gdm^{-3}$ of ammonium hydroxide, 30 ml of $0.153gdm^{-3}$ of Thiourea and 20ml of $1.542gdm^{-3}$ of ammonium acetate which brought the volume of the content of the bath to 95ml. The temperature of the bath was maintained at 90°C using 78HW-1 constant magnetic stirrer. The substrates were inserted vertically with the aid of a stand and clips. The deposition was allowed to take place at time intervals of (10, 30, and 50) minutes respectively after which the substrates were removed from the bath simultaneously and rinsed with de-ionized water and then annealed in an oven at a temperature of 400°C for 60 minutes. we used the gravimetric method in calculating the thickness of the film grown in this work. This method is based on the direct determination of the mass deposited onto the glass substrate. The substrate was weighed before deposition and reweighed after deposition; the thickness was determined using relevant equation. The samples were characterized for optical properties using a single - beam UV-VIS Helios omega spectrophotometer by measuring the absorption of the samples within the wavelength range of (280 – 920) nm.

3. RESULTS AND DISCUSSION

3.1 Optical Characterization

Optical measurements of transmittance and absorbance of the films deposited at different deposition times are shown in figure 1 and 2. These measurements have been taken in the wavelength range of (280 – 920) nm. The transmittance was calculated using equation(2) [35,36]

$$T = \frac{1}{10^A} \quad 1$$

where A is absorbance as recorded from the spectrophotometer.

From equation (1) it can be understood that

$$A \log_{10} T \quad 2$$

where A is absorbance

The coefficient of absorption (α) was calculated from the absorbance data using Beer Lamberts law [37] which relates the transmittance (T), absorbance (A) and thickness (d) of the film as shown in equation (3a, b)

$$T = e^{-\alpha d} \quad 3a$$

So that

$$\alpha = 2.303 \frac{A}{d} \quad 3b$$

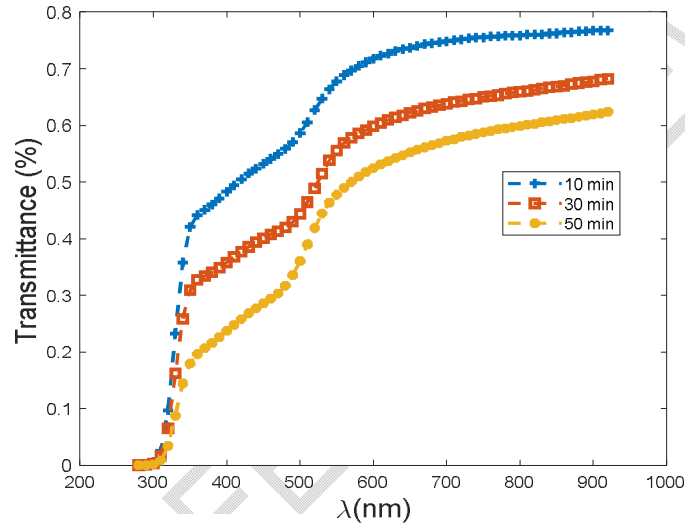


Fig. 1. Variation of Transmittance with the wavelength

Fig. 1 is the display of the variation of the percentage transmittance with the wavelength λ , from the figure, the deposited thin films showed strong transmittance along the visible range of the spectrum with the transmittance in the order of 10 min > 30 min > 50 min whereas below the absorption edge the transmittance was near zero. It may be that the deposition time have affected the thickness of the film thereby slowing down the speed of the incident wave within the material. The similar phenomenon has been reported in the literature [5, 38,]. Fig. 2 also is a display of the absorbance spectra which show that the deposited films exhibited strong absorbance and weak transmittance within the wavelength region of $\lambda < 350 \text{ nm}$ but above that wavelength there was a good transmittance which is due to excitation and migration of the electrons from the valence band to the conduction band[39].

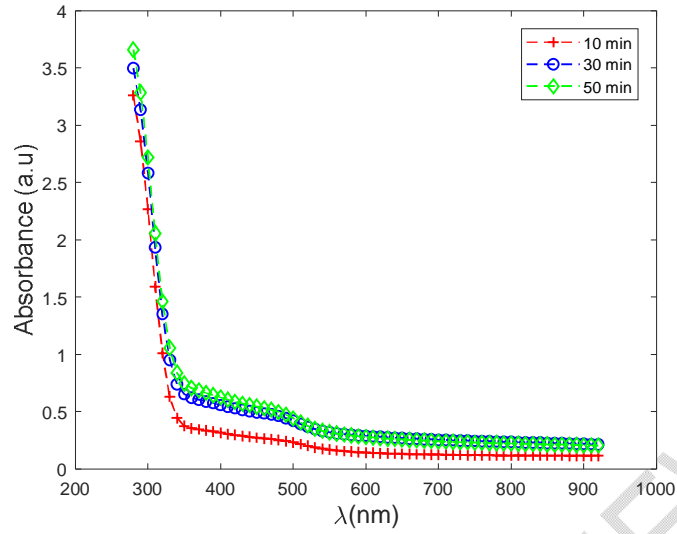


Fig. 2. Variation of absorbance with the wavelength

3.2.1 Optical energy gap.

The optical bandgap of CdS was obtained from the Absorbance data using the Tauc's relation [40] as shown in equation (4).

$$(\alpha h\nu) = A(h\nu - E_g)^m \quad 4$$

Where A is a constant called the band tailing parameter, E_g is the bandgap corresponding to a particular transition occurring in the film, ν is the transition frequency, h is the planks constant given by $6.63 \times 10^{-34} \text{ m}^2 \text{ kg s}^{-1}$, The value of m which is the characteristic nature of the band could be $\frac{1}{2}$, $\frac{3}{2}$, 2, or 3 depending on the nature of the electronics transition responsible for absorption, $m = \frac{1}{2}$ for direct band gap semiconductors. An extrapolation of the linear region of the plot of $(\alpha h\nu)^2$ vs $h\nu$ gives the value of optical band gap E_g . [41]

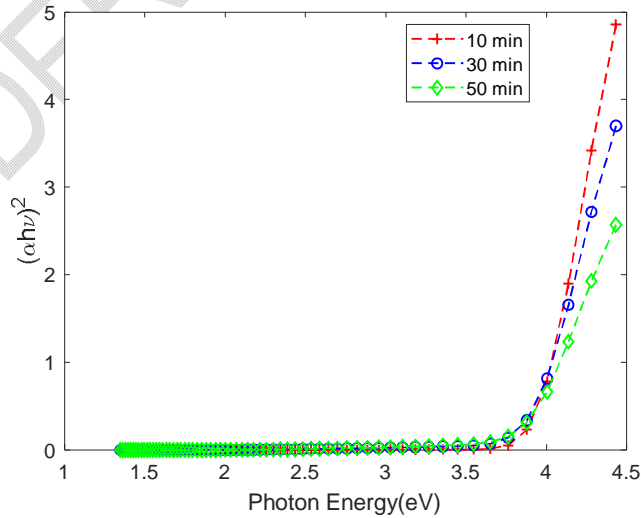


Fig. 3. Plot of $(\alpha h\nu)^2$ vs $h\nu$ of CdS thin film of different deposition time

Figure 3 shows the bandgap energy values of the CdS thin films with different deposition times of 10, 30, and 50 minutes and is listed in table 1. From the result, the bandgap values were found to be higher than that of the bulk material with the film deposited for 10 minutes having higher and that of 50 minutes having the lowest. This condition have been attributed to quantum confinement by some researchers [37, 42] The result we obtained is similar to those reported by other researchers [3, 37,42, 43,]. This phenomena is as a result of the breaking down of the continuum density of state into discrete levels such that bandgap energy widens compared to the bandgap of the bulk.[44,45,46].

3.2.2. Refractive index analysis;One of the distinctive and essential property of an optical material is its refractive index n.

“This is because it is one of the major factors to be considered in selecting materials used for fabricating optical devices or for optical applications. Therefore, it is essential to understand the refractive index of a material since many optical phenomena are dependent on its value. The refractive index η is closely related to both electronic polarization of ions and the local field inside the optical materials” [47]. The refractive index η was determined using equation (5) [48, 49]

$$\eta = \frac{1+\sqrt{R}}{1-\sqrt{R}} \quad 5$$

where R is the reflectance of the film. The refractive index η of the thin films as a function of photon energy is shown in fig. 4. From the figure the refractive index peaks near $\sim 2.5eV$ and attains the highest peak at ~ 3 .with the thin film that has the lowest deposition time having the highest peak which is an indication that the deposition time influences the refractive index. Many researchers have attributed these peaks to optical transition from valence band to conduction[38]. This shifting of the peaks position is indicative of the change in the optical bandgap of the thin films.

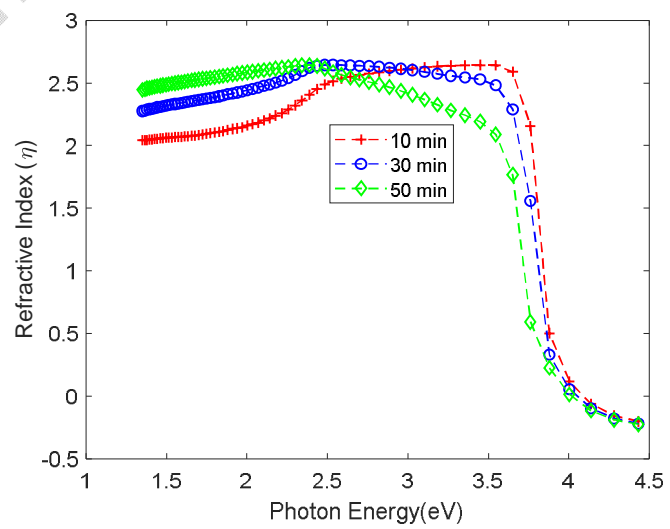


Fig. 4.Plot of Refractive Index (η)vs($h\nu$) of CdS thin film of differentdeposition time

3.2.3 Extinction coefficient

The extinction coefficient k is determined using equation (6) [48, 49]

$$K = \frac{\alpha\lambda}{4\pi} \quad \text{6 where } \alpha \text{ is the absorption coefficient and } \lambda \text{ is the wavelength of the incident beam.}$$

The extinction coefficient also known as the absorption index is so important in determining several optical measurements that are related to the absorption of light waves in the medium and dielectric constant [50]. "The extinction coefficient k spectra as a function of incident wave is shown in fig 5. The figure reveals that the extinction coefficient K decreases with increase in wavelength of the incident photons. At the lower values of K , it should be noted that light energy lost by scattering and absorption per unit distance was having small values when light propagates through the thin films". [50] Also observed was that the thin film deposited for 30 min have higher K as compared to others which means that there was more scattering of light which may be as a result of impurities or surface morphology. However, the lower values of K at the visible region of the spectrum is an evidence that less light was lost by scattering hence the material is good for optical devices.

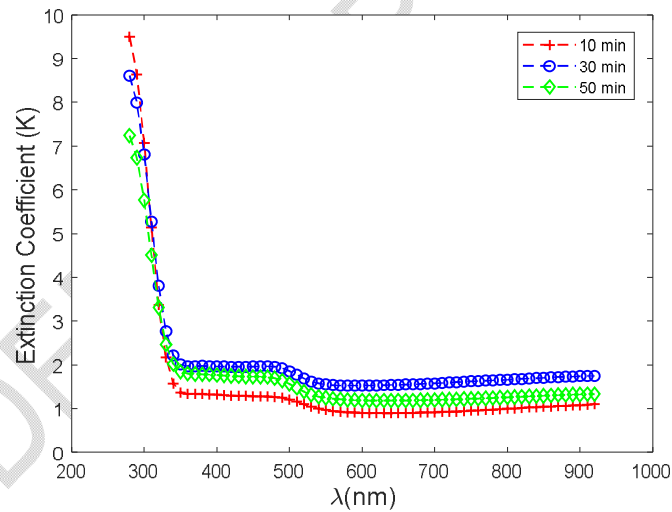


Fig. 5. Plot of Extinction Coefficient (K) vs Wavelength λ (nm) of CdS thin film for different deposition time

The figure shows that the extinction coefficient decreases with increase in the incident waves.

3.2.4 Dielectric constant analysis

"The fundamental electron excitation spectra of CdS thin film are described with complex dielectric constant ϵ^* . The real part of dielectric constant ϵ_r is related with the property of slowing down the speed of light in materials as well as dispersion of electromagnetic waves

that travels within the material whereas the imaginary part of the dielectric constant ϵ_i provides a measure of the disruptive rate of the wave in the material, meaning that it is responsible for the energy absorption from electric field due to dipole motion" [51, 52]. The values of real and imaginary part of the dielectric constant were obtained using equation (7 a, & b) [53] and shown in figure 6 and 7.

$$\epsilon_r = \eta^2 - k^2 \quad 7a$$

and

$$\epsilon_i = 2\eta k \quad 7b$$

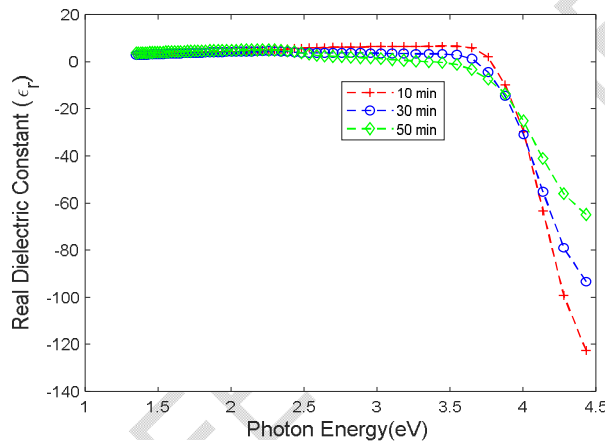


Fig. 6. Plot of *Real Dielectric Constant (ϵ_r) vs Photon energy (eV)* of CdS thin film of different deposition time

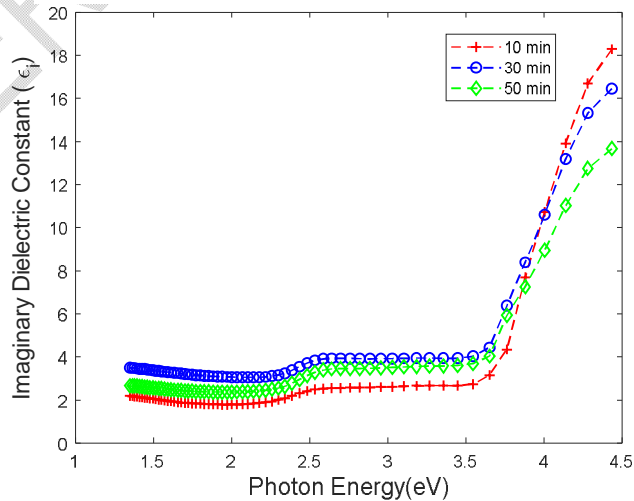


Fig. 7. Plot of *Imaginary Dielectric Constant (ϵ_i) vs Photon energy (eV)* of CdS thin film of different

Fig. 6 is a display of the real dielectric constant as a function of photon energy, within the range of $\sim 1.5eV - 2.5eV$, the three films exhibited the same behaviour whereas near the absorption edge as the photon energy is increased there was a gradual shift in the dielectric constant in the order 10 min > 30 min > 50. Fig. 7 also show the imaginary dielectric constant as a function of photon energy which show an exponential increase as the photon energy increase after the absorption edge. This view is in agreement with the assertion of Davis & Mott. [50,54].

3.2.5 Dispersion energy parameters

In optical communication and designing devices, the dispersion of the refractive index is very important. The spectral dispersion is obtained from the Wemple DiDomenico model given in equation (8).[55]

$$\eta^2 - 1 = \frac{E_d E_o}{E_o^2 (h\nu)^2} \quad 8$$

where E_d is dispersion energy and is related to the strength of the inter band optical transition. E_o is the oscillator energy which gives the quantitative information on the overall band structure of the CdS thin film. By plotting $\frac{1}{n^2 - 1}$ against the square of the photon energy $(h\nu)^2$ as shown in figure 8a. The values of E_d and E_o are calculated from the slope $(E_o E_d)^{-1}$ and intercept (E_o/E_d) on the vertical axis as extracted from the linear fit of each of the deposited sample is given in table 1. From the values of E_d and E_o , the static refractive index (η_o) and static dielectric constant (ϵ_o) are calculated using equation (9) [55].

The values of E_d and E_o are comparable to the result reported by Wemple and DiDomenico[53]. The Wemple DiDomenico model have the advantage of providing an intuitive physical interpretation of measured quantities and have been used severally even in ternary chalcogenide systems. This is because it gives information concerning three different energies which are; The average energy gap or the oscillator energy or the effective single oscillator energy E_o of the material which give the overall information of the band structure of the material. Another energy is the dispersion energy E_d which is a measure of the inter-band optical transition and it has to do with the ionicity, anion valency and coordination of the material. The third energy is the incident photon $h\nu$. From the result listed in table 1, the values of E_o decreases as the deposition time increases and also the values of E_d deposited at 30 min is greater that deposited at 50 min and 10 min respectively. This could mean that it requires grater energy for inter band optical transitions. The similar phenomenon has been reported in the literature[56, 57].

$$\varepsilon_o = \eta_o^2 = 1 + \frac{E_d}{E_o} \quad 9$$

The moments of optical dispersion spectra m_{-1} and m_{-3} are evaluated from equation (10a) and (10b)

$$E_o^2 = \frac{M_{-1}}{M_{-3}} \quad 10a$$

And the values of η_o , ε_o , M_{-1} and M_{-3} are listed in table 1.

$$E_d^2 = \frac{M_{-1}^3}{M_{-3}} \quad 10b.$$

The values of η_o and ε_o as listed in table 1 are seen to be increasing as the deposition time is increasing. However, it is noted that at the deposition time of 50 min, the high frequency refractive index (η_∞) is the same as the static refractive index (η_o) and the high frequency dielectric constant (ε_∞) is the same as the static dielectric constant (ε_o). also from the table the values M_{-1} and M_{-3} were found to be increasing as the deposition time. Our result can be compared to the result reported by Ikhmayies [58].

The Wemple–Didomenico formula can be modified to find the static optical index of refraction at infinite wavelength [58,59, 60] in the form of

$$\frac{\eta_\infty^2 - 1}{\eta^2 - 1} = 1 - \left(\frac{\lambda_0}{\lambda} \right)^2 \quad 11a$$

By plotting $\frac{1}{\eta^2 - 1}$ against λ^{-2} of CdS as shown in figure 8b, the high frequency refractive index (η_∞) was calculated from the intercept extracted from the linear fit of each of the deposited sample whereas $\eta_\infty^2 = \varepsilon_\infty$ and were also listed in table 1.

TABLE 1. OPTICAL AND DISPERSION PARAMETERS OF CdS THIN FILMS

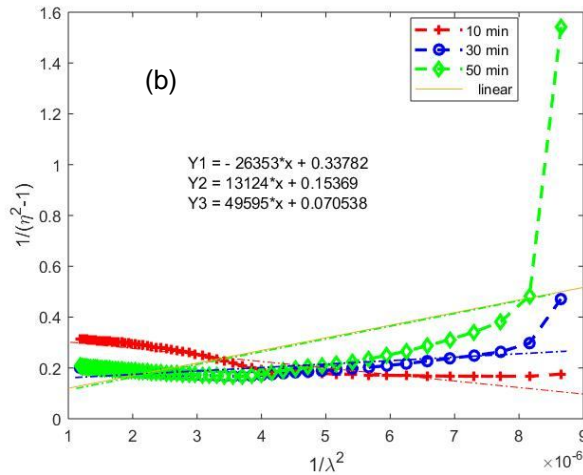
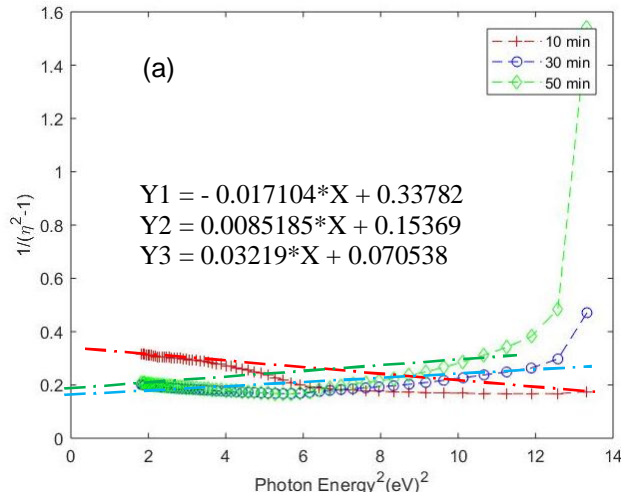
| Time | 10 min | 30 min | 50 min |
|----------------------|--------------------------------------|--------------------------------------|-------------------------------------|
| E_g | 3.78 eV | 3.72 eV | 3.70 eV |
| E_d | 13.16 eV | 27.64 eV | 20.98 eV |
| E_o | 4.44 eV | 4.25 eV | 1.48 eV |
| η_o | 1.99 | 2.75 | 3.90 |
| ε_o | 3.96 | 7.58 | 15.18 |
| M_{-1} | 2.96 | 6.50 | 14.18 |
| M_{-3} | 0.1502 eV ² | 0.36 eV ² | 6.47 eV ² |
| S_0 | 3.795×10^{-5} | 7.62×10^{-5} | 2.02×10^{-5} |
| λ_o | 279.30 nm | 292.22 nm | 838.50 nm |
| η_∞ | 1.72 | 2.74 | 3.90 |
| ε_∞ | 2.96 | 7.51 | 15.18 |
| ε_L | 7.02 | 5.99 | 5.30 |
| $\frac{N}{M^*}$ | $1.62 \times 10^{41} kg^{-1} m^{-3}$ | $2.31 \times 10^{41} kg^{-1} m^{-3}$ | $5.8 \times 10^{41} kg^{-1} m^{-3}$ |
| ω_p | $1.25 \times 10^6 Hz$ | $8.18 \times 10^5 Hz$ | $1.30 \times 10^6 Hz$ |

| | | | |
|------------|-----------------------------|-----------------------------|-----------------------------|
| α_p | $9.27 \times 10^{-33} Fm^2$ | $7.90 \times 10^{-33} Fm^2$ | $1.01 \times 10^{-33} Fm^2$ |
|------------|-----------------------------|-----------------------------|-----------------------------|

Using the single Sellmeier oscillator model, [50] equation (11b), the oscillator strength and oscillator wavelength of CdS thin film were evaluated and listed in table 1.

$$\eta^2 - 1 = \frac{S_o \lambda_o^2}{1 - \left(\frac{\lambda_o}{\lambda}\right)^2} \quad 11b$$

Where λ is incident wavelength, S_o is oscillator strength and λ_o is oscillator wavelength. By plotting $\frac{1}{\eta^2 - 1}$ against λ^{-2} of CdS as shown in figure 8b. The values of S_o and λ_o are obtained from the slope and intercept extracted from the linear plot of all the deposited samples and are listed in table 1, which show that S_o value for film deposited for 30 min is greater than S_o value for films deposited for 10 min and 50 min respectively while λ_o increases with increase in deposition time. The lattice dielectric constant (ϵ_L) of CdS thin film is also calculated from equation (12) [61].



$\frac{1}{\eta^2 - 1}$ Versus $h\nu^2$ (b) $\frac{1}{\eta^2 - 1}$ Versus $\frac{1}{\lambda^2}$

$$\eta^2 = \varepsilon_L - \left[\frac{e^2}{4\pi c^2 \varepsilon_0} \frac{N}{M^*} \right] \lambda^2 \quad 12$$

where e is the charge of electron, c is the speed of light, ε_0 is the permittivity of free space, $\frac{N}{M^*}$ is the ratio of number of free charge carriers and effective mass of electrons. Also, the plasma resonance frequency ω_p which is referred to as the material change from metallic to dielectric can be evaluated from the curve n^2 versus λ^2 using equation (13) [50].

Using Fig. 8c, the values of ε_L , $\frac{N}{M^*}$ and ω_p were obtained and listed also in table 1. The lattice energy ε_L gives information about the strength of the bonds in ionic compound. This is a potential that acts on the electrons, restoring it to its mean position when incident's light electric field sends it into oscillation. As is observed from the table, the lattice energy of the deposited thin film increases as the deposition time increases.

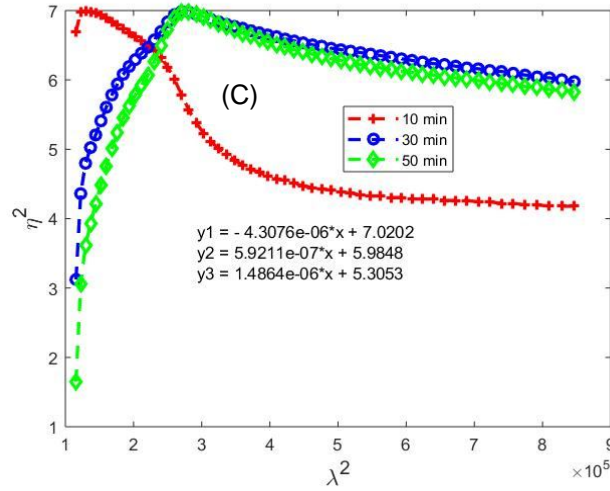


Fig8 (c) η^2 Versus λ^2

3.2.6 Electronic polarizability

“The electronic polarizability (α_p) gives the degree of the electronic response to the application of an electromagnetic field on the electron clouds” [56]. The polarizability (α_p) of CdS thin film can be evaluated using Lorenz - Lorentz equation and Clausius Mossotti local field model [61, 62] as shown in equation (14).

$$\left(\frac{\eta^2 - 1}{\eta^2 + 2} \right) = \frac{N_A \rho}{3 \varepsilon_0 M} \alpha_p \quad 14$$

where η is the refractive index, N_A is the Avogadro's number M is the molar mass of bulk CdS and ρ is the density of bulk CdS. Therefore, the plot of $\frac{\eta^2 - 1}{\eta^2 + 2}$ against $h\nu$ of CdS thin film is shown in figure 8(d). The intercept of plot on the vertical axis gives the value of α_p and

listed in table 1, as extracted from the linear plot of the deposited samples. From Fig. 8d it is observed that within $\sim 2.5\text{eV}$ all the deposited thin films have the same response to the application of photon energy, but as the photon energy increases, the electronic response changes with the thin film deposited for 10 min having the highest response.

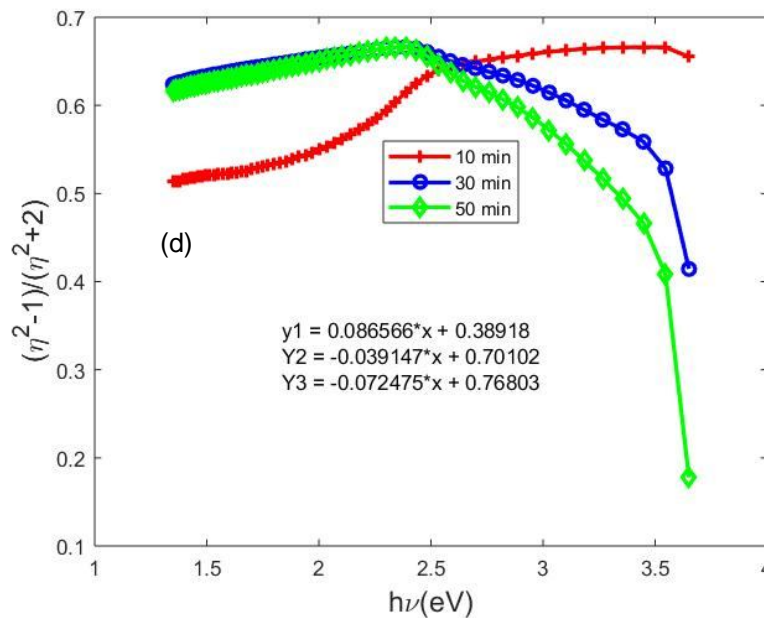


Fig8 (d) $\frac{\eta^2-1}{\eta^2+2}$ Versus $h\nu$ (eV) Fig8 (a)

4.0 Conclusion

Cadmium Sulphide (CdS) thin film was deposited by chemical bath deposition technique on a transparent glass substrate. The CdS thin film has a very high transmittance through the entire electromagnetic spectral range which justify it as a good material for optoelectronic devices and solar cells. The dielectric constant was evaluated from the linear refractive index and extinction coefficient. The dispersion parameters (E_d , E_0 , moment of optical spectra S_0 , λ_0 , $\frac{N}{M^*}$, ω_p , and α_p), dielectric constants (η_0 , η_∞ , and E_L) have been evaluated using Wemple DiDomenico model and single Sellmeier oscillator model. The electronic polarizability of CdS thin film was evaluated using Clausius - Mossotti local field polarizability model.

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